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Form PTO-1449		U.S. DEPARTMENT OF COMMERCE		ATTY. DOCKET NO.		SERIAL NO.				
(MODIFIED)		PATENT AND TRADEMARK OFFICE		039153-0363 (F0804)		09/900,986				
O P DEFORMATION DISCLOSURE CITATION				APPLICANT Subramanian, et al.						
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DEC 1 0 2001	(in se se	e several sheets if necessary)			07/09/2001		2812			
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Form PTO-1449	U.S. DEPARTMENT OF COMMERCE	ATTY. DOCKET NO. ,	SERIAL NO.		
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